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Decomposition of MgSiN₂ in nitrogen atmosphere

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Abstract

Magnesium silicon nitride MgSiN₂ was prepared by direct nitridation of Si/Mg₂Si/Mg/Si₃N₄ powder compact in a temperature range 1350–1420 °C. The thermal stability examination showed that MgSiN₂ is stable up to 1400 °C at 0.1 MPa N₂ pressure. The activation energy of decomposition of MgSiN₂ calculated from the temperature dependence of mass loss in the range of 1400–1650 °C is $\Delta H = 501$ kJ mol⁻¹. The time dependence and nitrogen pressure dependence of MgSiN₂ decomposition was also investigated at constant temperature. MgSiN₂ is stable at 1560 °C in 0.6 MPa nitrogen atmosphere. Using these experimental data together with the heat capacity published in a literature the Gibbs energy of formation of MgSiN₂ was calculated in a temperature range 25–2200 °C. © 2011 Elsevier Ltd. All rights reserved.

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1. Introduction

In the past two decades great attention has been given to the development of nitride-based ceramic materials with high thermal conductivity. The most promising results have been achieved for AlN and Si₃N₄ with thermal conductivity 260 and 162 W(m K)⁻¹, respectively.^{1,2} Except of special processing methods like seeding, tape casting, or extrusion with a goal to obtain highly oriented microstructure, the main attention of research groups is focused on the grain boundary chemistry. It was confirmed that the lattice oxygen has a deleterious effect on thermal conductivity.³ For that reason rare-earth oxides (e.g. Y₂O₃, Yb₂O₃, Nd₂O₃, etc.) or nonoxide sintering additives like fluorides, nitrides, or borides are used for the sintering of AlN or Si₃N₄ with high thermal conductivity.⁴ Hayashi et al.⁵ reported thermal conductivity over $140 \text{ W}(\text{m K})^{-1}$ for sintered Si₃N₄, using Yb₂O₃, MgO and MgSiN₂ as sintering additives. Besides MgO also MgSiN₂ was used as a supplier of Mg²⁺ ions, which decreased the melting point of silicate glass, but without increasing the oxygen content in the liquid phase. During thermal annealing at 1900 °C and 0.9 MPa nitrogen pressure MgSiN₂ decomposed to Mg and N₂ vapours, and to solid Si₃N₄.

0955-2219/\$ - see front matter © 2011 Elsevier Ltd. All rights reserved. doi:10.1016/j.jeurceramsoc.2011.02.023 Magnesium can pick up some oxygen from the silicate melt, evaporates also in a form of MgO gas and decreases the total oxygen content in the sintered body. This "cleaning effect" resulted in higher thermal conductivity. The main disadvantage of the applied method was the long annealing time at very high temperature.

The conditions for the evaporation of MgO from partly sintered Si_3N_4 body were already published,⁶ however, concerning the decomposition of MgSiN₂ there is a lack of data. In earlier works it was reported that MgSiN₂ is stable at 1500 °C in nitrogen atmosphere and the approximate Gibbs free energy of MgSiN₂ can be described by the following equation⁷:

 $G(MgSiN_2) = -165,000 + 75.96T$ (J/g-atom).

On the other hand Uchida et al. observed the decomposition of MgSiN₂ to α -Si₃N₄ and β -Si₃N₄ at temperatures exceeding 1400 °C.⁸ Groen et al. reported the decomposition of MgSiN₂ at 1550 °C in welded molybdenum vessel in argon ambient.⁹ They found bubbles inside the sintered pellets probably due to the evaporation of Mg during sintering. When MgSiN₂ powder bed was used, the decomposition was successfully suppressed. These results suggest that the decomposition of MgSiN₂ starts at temperatures 1400–1500 °C in nitrogen atmosphere. Because the temperature range is relatively wide and the nitrogen pressure was also different, more detailed study is necessary. The ther-

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mal stability data are also important for the sintering process above 1500 °C, when MgSiN₂ should remain in the product. Composites on the base of MgSiN₂ and Si₃N₄ with promising mechanical properties have been prepared by sintering at temperatures 1500–1650 °C and in nitrogen overpressure.^{10–14} However, after sintering at these temperatures under 0.1 MPa N₂ atmosphere remarkable mass loss of 10–15% has been observed.¹¹

The knowledge of thermal stability of $MgSiN_2$ is important also for the synthesis of long lasting phosphors, e.g. europium-doped $MgSiN_2$.^{15–17}

The aim of this work was to study the decomposition of MgSiN₂ powder compacts in a temperature range 1400–1650 °C and 0.1 MPa nitrogen atmosphere. Some additional experiments in higher nitrogen pressure $p(N_2) \le 0.8$ MPa and at constant temperature have been also carried out.

2. Experimental

MgSiN₂ powder was prepared from the mixture of Mg₂Si (99%, Kojundo Chem. Lab., Japan), α -Si₃N₄ (grade E-05, Ube Industries Ltd., Japan), Si (99.9%, Kojundo Chem. Lab., Japan), and Mg (grade Mg-100, Yamaishi Metal Co., Japan). The details of powder preparation are described elsewhere.¹⁸ Briefly, stepwise heating was applied up to the final temperature of nitridation at 1380 °C and 0.1 MPa N₂ atmosphere. XRD analysis showed a single-phase MgSiN₂. The powder contained 33.36 wt% nitrogen and 0.62 wt% oxygen, determined by N/O analyzer (model TC-436, LECO Co., St. Joseph, MI).

The decomposition experiments were carried out in high purity nitrogen atmosphere (grade 5N) under conditions similar to the real sintering process. Differential thermal analysis (DTA) and thermogravimetry (TG) were conducted using TG-DTA apparatus (Thermo Plus TG 8120, Rigaku, Japan) with Al_2O_3 sample holders applying a constant heating rate of 5 °C min⁻¹ in flowing nitrogen atmosphere (80 cm³ min⁻¹) up to 1400 °C.

The decomposition experiments of MgSiN₂ were carried out in the temperature range of 1400–1650 °C on larger pellets (16 mm diameter, 2 mm height), prepared from the above mentioned MgSiN₂ powder by die-pressing (70 MPa) and coldisostatic pressing (400 MPa). The samples were placed into a BN crucible on MgSiN₂ pin-holders and annealed in alumina tube furnace ($\phi = 80$ mm, Motoyama Ltd., Japan) with a heating rate of 3 °C min⁻¹ and a holding time for 2 h at the final temperature. The nitrogen gas flow was maintained at 1.5 L min⁻¹ during the measurements.

Decomposition experiments were carried out also in graphite gas-pressure furnace with nitrogen overpressure up to 0.8 MPa. The nitrogen gas flow was $1.5 \text{ L} \text{ min}^{-1}$. The sample was placed into BN crucible and then to the larger graphite crucible. The inner walls of graphite crucible were coated with BN to decrease the carbon activity. In the graphite resistance furnace the temperature was controlled by pyrometer. Because the crucibles shielded the samples from heat radiation, the temperature was re-calibrated after the experiments: hole was drilled into the used crucibles, thermocouple was inserted and the real temperature near the sample was measured.

Table 1

Mass loss $\Delta m/m_0$ of MgSiN₂ samples after heat treatment at particular temperatures for 2 h in 0.1 MPa nitrogen atmosphere.

Temperature (°C)	1400	1450	1500	1550	1600	1650
$\Delta m/m_0 \text{ (wt\%)}$	-0.4	-1.9	-4.5	-13.2	-22.9	-44.3

The phase composition of heat treated samples was analysed by X-ray diffraction (XRD) measurements using Cu K α radiation (RINT2500, Rigaku Co., Japan) with a scanning rate $2 \,^{\circ}\text{Cmin}^{-1}$ and step 0.010° in the range $2\theta \in \langle 20^{\circ}; 70^{\circ} \rangle$. The microstructural observation and elemental analysis were carried out by field-emission scanning electron microscope (JEOL JSM-6330F, Japan), equipped with energy-dispersive spectrometer (EDS, JEOL JED-2140, Japan).

3. Results and discussion

3.1. Thermal stability

The DTA-TG measurement did not show any significant decomposition of MgSiN₂ up to 1390 °C in 0.1 MPa nitrogen atmosphere. There was a mass loss of 0.67 wt% up to 600 °C, due to the removal of absorbed humidity from the samples (preannealed at 110 °C). Similarly, sample annealed up to 1300 °C in alumina tube furnace and 0.1 MPa nitrogen pressure showed mass loss of 0.72 wt%. Based on the results of these experiments, all the measured mass loss data were corrected by the systematic error of 0.7 wt%. The DTA-TG measurement showed slight weight loss starting at 1331 °C, but it was only 0.2 wt% in total measured on 58.5 mg sample in the range of 700–1390 °C.

The results of decomposition measurements of MgSiN₂ at temperatures above 1400 °C in alumina tube furnace are summarised in Table 1. The decomposition of MgSiN₂ starts at ~1400 °C in flowing nitrogen atmosphere. XRD measurement showed that after annealing of MgSiN₂ at this temperature a small amount of α -Si₃N₄ was formed in the product by the decomposition of ternary nitride. It was reported that MgSiN₂ decomposes after annealing in vacuum (1.3 Pa) at temperatures from 1000 °C to 1400 °C into Si₃N₄ and Mg₃N₂.¹⁹ However, in the temperature range from 1400 °C to 1650 °C the proposed reaction of decomposition is the following:

$$3MgSiN_2(s) = 3Mg(g) + N_2(g) + Si_3N_4(s)$$
(1)

because Mg_3N_2 decomposes at these temperatures.²⁰ The theoretical mass loss according to reaction (1) is 41.8 wt%. Sample annealed at 1650 °C for 2 h had a mass loss of 44.3 wt% (Table 1). This difference indicates that Si_3N_4 should partly decompose already at 1650 °C. The decomposition of MgSiN₂ above 1650 °C can be expressed by reaction:

$$3MgSiN_{2}(s) = 3Mg(g) + 3xSi(l) + (1 - x)Si_{3}N_{4}(s) + (1 + 2x)N_{2}(g)$$
(2)

where $x \in \langle 0; 1 \rangle$. According to JANAF thermochemical tables the decomposition temperature of Si₃N₄ is 1878 °C in 0.1 MPa



Fig. 1. The phase composition of $MgSiN_2$ samples heat treated for 2 h in 0.1 MPa nitrogen atmosphere at different temperatures.

nitrogen atmosphere.²⁰ However, in practice the decomposition of Si₃N₄ is enhanced by impurities like carbon, oxygen, etc.^{21,22} The starting MgSiN₂ powder used in this work contained 0.62 wt% oxygen, which is partly removed during annealing in a form of SiO(g) and MgO(g), resulting in ~1.7 wt% mass loss. Even with this contribution, the weight loss should not exceed 43.5 wt% (Table 1), if Si₃N₄ does not decompose at 1650 °C. All the results indicate the decomposition of Si₃N₄. Moreover, the product had a brownish colour after heat treatment at 1650 °C, while samples annealed at lower temperatures were white. It suggests to the presence of free silicon, however, it was bellow the detection limit of XRD analysis. Most probably the magnesium vapour catalysed the decomposition of Si₃N₄ (see Eq. (2)) at this relatively low temperature. David et al. reported that magnesium can reduce Si₃N₄ already at 1000 °C.²³

The phase composition of annealed samples is shown in Fig. 1. α -Si₃N₄ is the major decomposition product. β -Si₃N₄ was formed at 1550 °C as a minor phase, and its content increased with increasing temperature. The MgSiN₂ content in sample annealed at 1650 °C for 2 h in 0.1 MPa nitrogen



Fig. 3. EDX analysis of rod-like β -Si₃N₄ grains formed by decomposition of MgSiN₂ showing the presence of magnesium.

atmosphere was close to the lowest detection limit of XRD analysis.

The microstructure evolution of heat treated samples is shown in Fig. 2a–e. The powder agglomerates were partly sintered at 1400 °C, and at 1500 °C channels were formed between the grains by the evaporation of decomposition products. At 1650 °C rod-like β -Si₃N₄ grains were formed, however the EDS analysis of these grains shows the presence of small amount of magnesium (Fig. 3). Very often porous channels were observed within the elongated grains formed above 1600 °C (Fig. 2e).

The activation energy for decomposition of $MgSiN_2$ was estimated from the mass loss data shown in Fig. 4. The mass change as a function of temperature can be expressed by the approximate equation²⁴:

$$\frac{\Delta m}{m_0} \approx \frac{ART^2}{\Delta H} \exp\left(-\frac{\Delta H}{RT}\right)$$
(3)

where *m* is the mass of sample, *A* the pre-exponential factor, *R* the gas constant and ΔH is the change of enthalpy.



1650°C/2h

Fig. 2. Microstructure evolution of heat treated MgSiN₂ samples.



Fig. 4. The mass change as a function of temperature. The activation energy of decomposition $\Delta H = 501 \text{ kJ mol}^{-1}$ was determined from the plot of $\ln(\Delta m/m_0)$ as a function of 1/T.

The activation energy of decomposition $\Delta H = 500.7 \text{ kJ mol}^{-1}$ was determined from the plot of $\ln(\Delta m/m_0)$ as a function of 1/*T*. It should be noted that the enthalpy of formation $\Delta_f H_{298}^{\circ}$ for Mg₃N₂ and α -Si₃N₄ is -461.08 kJ mol⁻¹ and -744.75 kJ mol⁻¹, respectively.²⁰ Recent calorimetric studies gave enthalpies of formation -828.9 kJ mol⁻¹, ^{25,26} or -850.9 kJ mol⁻¹ for α -Si₃N₄.²²

The time dependence of isothermal decomposition of MgSiN₂ was measured in alumina tube furnace at 1600 °C and 0.1 MPa nitrogen pressure. The results are shown in Fig. 5, where α is the fractional decomposition of MgSiN₂. The computation of the kinetic parameters was based on the Arrhenius equation applied to solid-state reactions, although its applicability is still the subject of debate. The decomposition data did not follow any of the mathematical models for solid-state reactions summarised by Šesták and Berggren for the whole time interval.²⁷ The initial decomposition is localised at the surface, and with the extent of reaction most probably the reaction mechanism is changed. For this reason the initial stages of decomposition (t < 10 min) were fitted to the first order reaction mechanism $d\alpha/dt = k(1 - \alpha)$,²⁸



Fig. 5. The time dependence of isothermal decomposition of MgSiN_2 at 1600 $^\circ\text{C}$ and 0.1 MPa nitrogen pressure.

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Influence of nitrogen pressure on the mass loss (decomposition) of $MgSiN_2$ at 1560 °C and holding time for 2 h.

N ₂ pressure (MPa)	0.1	0.3	0.4	0.5	0.6	0.8
Mass loss (wt%)	14.53	4.71	1.17	0.95	0.06	0.04

while for time t > 30 min the Jander's kinetic model has been applied²⁹:

$$[1 - (1 - a)^{1/3}]^2 = \left(\frac{KD}{r^2}\right) \cdot t = k_J \cdot t$$
(4)

Coefficient *K* is determined by the chemical potential difference for the species diffusing across the reaction layer, *D* is the diffusion constant and *r* the radius of spherical particles. The linear fit of decomposition data in Fig. 5 yields the rate constant $k_J = 8.51 \times 10^{-7} \text{ s}^{-1}$ in Eq. (4). The temperature dependence of the reaction-rate constant follows also the Arrhenius equation $k_A = A \exp(-\Delta H/RT)$. Substituting the activation energy of decomposition $\Delta H = 500.7 \text{ kJ} \text{ mol}^{-1}$ (Fig. 4) and temperature 1873 K yields $k_A = A \times 1.09 \times 10^{-14} \text{ s}^{-1}$. The pre-exponential factor $A = 7.82 \times 10^7$ results from $k_J = k_A$. Finally, the temperature dependence of reaction-rate constant for time t > 30 min can be expressed by:

$$k = 7.82 \times 10^7 \exp\left(\frac{-60, 224}{T}\right) \,\mathrm{s}^{-1}$$
 (5)

It should be pointed out that the simplifications limit the range over which Eq. (5) adequately predicts the reaction rates. Jander's Eq. (4) is valid only for small reaction thickness and the molar volume change between the reactants and products was neglected; $V_{m,298}(MgSiN_2) = 2.562 \times 10^{-5} \text{ m}^3 \text{ mol}^{-1}$, $V_{m,298}(Si_3N_4) = 4.381 \times 10^{-5} \text{ m}^3 \text{ mol}^{-1}$.³⁰ However, due to the lack of the kinetic parameters determined by more precise methods, Eq. (5) gives at least a rough estimation of the decomposition rate of MgSiN₂.

The influence of nitrogen pressure on the decomposition of MgSiN₂ was investigated in graphite resistance gas pressure furnace at 1560 °C with a holding time of 2 h and nitrogen gas flow $1.5 L \text{ min}^{-1}$. The results are summarised in Table 2 and shows that MgSiN₂ is stable at 1560 °C under 0.6 MPa nitrogen pressure.

Table 3

The coefficients and statistics used for describing the isobaric heat capacity C_p° (see Eq. (6)) of MgSiN₂ in a temperature range (300–1600) K from data in Bruls et al.³⁰

Coefficient Statistics a (J K ⁻¹ mol ⁻¹) 100.855 Data points 14 b (J K ⁻² mol ⁻¹) 1.542 × 10 ⁻³ χ^2 4.28 × 10 ⁻⁷ c (J K mol ⁻¹) -6,243,640 d (J K ⁻³ mol ⁻¹) -5.812 × 10 ⁻⁸ f (J K ² mol ⁻¹) 80,3546,405 d d				
$ \begin{array}{llllllllllllllllllllllllllllllllllll$	Coefficient		Statistics	
	$ \begin{array}{l} a \; (JK^{-1}mol^{-1}) \\ b \; (JK^{-2}mol^{-1}) \\ c \; (JKmol^{-1}) \\ d \; (JK^{-3}mol^{-1}) \\ f \; (JK^2mol^{-1}) \end{array} $	$\begin{array}{c} 100.855\\ 1.542\times 10^{-3}\\ -6,243,640\\ -5.812\times 10^{-8}\\ 80,3546,405\end{array}$	Data points χ^2	14 4.28×10^{-3}

$T(\mathbf{K})$	$C_P^{\circ} (\exp.)^a (\mathrm{J} \mathrm{K}^{-1} \mathrm{mol}^{-1})$	C_P° (calc.) ^b (J K ⁻¹ mol ⁻¹)	S° (J K ⁻¹ mol ⁻¹)	$(G^{\circ} - H_{298}^{\circ})/T (\mathrm{J}\mathrm{K}^{-1}\mathrm{mol}^{-1})$	$H^{\circ} - H^{\circ}_{298} (\text{kJ mol}^{-1})$	$\Delta_f H^\circ (\text{kJ mol}^{-1})$	$\Delta_f G^\circ (\mathrm{kJ} \mathrm{mol}^{-1})$
298	61.34	61.365	44.140	-44.140	0	-542.610	-483.320
300	61.71	61.699	44.552	-44.141	0.123	-542.624	-482.922
400	75.04	74.994	64.277	-46.748	7.012	-543.329	-462.888
500	83.07	83.064	81.952	-52.057	14.948	-543.277	-442.773
600	88.08	88.135	97.578	-58.368	23.526	-542.825	-422.709
700	91.45	91.505	111.434	-64.979	32.518	-542.196	-402.738
800	93.85	93.864	123.815	-71.573	41.793	-541.527	-382.860
900	95.63	95.588	134.975	-78.008	51.270	-540.908	-363.066
923		95.920	137.392	-79.458	53.473	-540.793	-358.582
1000	96.99	96.897	145.117	-84.220	60.897	-549.010	-342.645
1100		97.922	154.402	-90.184	70.640	-548.629	-322.003
1200	98.88	98.748	162.959	-95.897	80.475	-548.273	-301.418
1300		99.430	170.891	-101.364	90.385	-547.928	-280.860
1366	100.05	99.819	175.825	-104.844	96.961	-547.723	-267.358
1400		100.004	178.281	-106.597	100.358	-675.011	-257.161
1500	100.72	100.497	185.198	-111.609	110.383	-673.358	-227.374
1600		100.928	191.698	-116.414	120.455	-671.729	-197.694
1685		101.254	196.931	-120.345	129.048	-670.368	-171.708
1700		101.308	197.829	-121.024	130.567	-720.306	-162.199
1800		101.649	203.629	-125.454	140.715	-718.505	-129.714
1900		101.959	209.133	-129.714	150.896	-716.692	-97.334
2000		102.242	214.370	-133.817	161.106	-714.870	-65.053
2100		102.504	219.365	-137.773	171.344	-713.035	-32.861
2200		102.747	224.139	-141.591	181.606	-711.191	-6.345
2300		102.975	228.712	-145.280	191.893	-709.338	25.648
2400		103.191	233.099	-148.849	202.201	-707.475	57.568
2500		103.394	237.316	-152.303	212.53	-705.603	89.403

Table 4 Calculated thermodynamic properties of MgSiN₂ (reference temperature 298.15 K, standard state pressure 0.1 MPa).

^a Data from Bruls et al.³⁰
^b Calculated from Eq. (6) and Table 3.



Fig. 6. The calculated and experimental heat capacities of MgSiN₂ and AlN.

3.2. Estimation of $\Delta_f G^{\circ}(MgSiN_2)$

In order to estimate the Gibbs energy of formation for MgSiN₂, the thermodynamic functions S_T° and $H_T^{\circ} - H_{298}^{\circ}$ were calculated from the heat capacity of MgSiN₂ at constant pressure C_P° published by Bruls et al.^{30,31} The heat capacity data were obtained by DSC and adiabatic calorimeter measurements. We have fitted the heat capacity values in the temperature range (250–1600) K using the extended Maier–Kelley polynomial:

$$C_P^{\circ} = a + b \cdot T + c \cdot T^{-2} + d \cdot T^2 + f \cdot T^{-3}$$
(6)

The calculated coefficients are listed in Table 3 and the experimental data together with fitted curves are shown in Fig. 6. The 5-parameter polynomial (Eq. (6)) fits better the data compared to the basic Maier–Kelley polynomial ($C_P^{\circ} = a + b \cdot T + c \cdot T^{-2}$), especially at higher temperatures. The heat capacities of well characterised AlN are also plotted in Fig. 6. Owing to the same wurtzite-like structure of AlN and MgSiN₂, about the same average atomic mass and volume per atom, about the same sound velocity and Debye temperature, also the heat capacity per mole atoms (C_P/n , where *n* is the number of atoms in the substance)



Fig. 7. Estimation of the minimum and maximum values of the $\Delta_f G^\circ$ (MgSiN₂) from Eqs. (14) and (15).

should be nearly the same.³⁰ Fig. 6 shows a good agreement of C_P/n for both compounds.

The relative enthalpy $H_T^{\circ} - H_{298}^{\circ}$ and entropy S_T° functions were obtained by numerical integration of C_P° and C_P°/T functions. $S_{298}^{\circ} = 44.14 \text{ J mol}^{-1} \text{ K}^{-1}$ was adopted from Bruls et al.³¹ The enthalpy of formation of MgSiN₂ from elements was calculated using the Kirchhoff's law:

$$\Delta_f H_{298}^{\circ} = \Delta_f H_{298}^{\circ} + [H_{298}^{\circ} - H_0^{\circ}]_c - \sum [H_{298}^{\circ} - H_0^{\circ}]_e \quad (7)$$

where indices *c* and *e* denotes compound (MgSiN₂) and elements, respectively. The thermodynamic functions $H_{298}^{\circ} - H_0^{\circ}$ of elements were taken from NIST-JANAF tables,²⁰ H_0° (MgSiN₂) = -534 kJ mol⁻¹ and $(H_{298}^{\circ} - H_0^{\circ})_{MgSiN_2} = 8.278 \text{ kJ mol}^{-1}$ from Bruls et al.³¹ This dataset yielded the enthalpy of formation of MgSiN₂ at 298.15 K: $\Delta_f H_{298}^{\circ} = -542.6 \text{ kJ mol}^{-1}$. The enthalpy and the Gibbs free energy of formation for MgSiN₂ were calculated using the following equations²⁰:

$$\Delta_f H_T^{\circ} = \Delta_f H_{298}^{\circ} + [H_T^{\circ} - H_{298}^{\circ}]_c - \sum [H_T^{\circ} - H_{298}^{\circ}]_e \quad (8)$$

$$\Delta_f G_T^{\circ} = \Delta_f H_T^{\circ} - T[(S_T^{\circ})_c - \sum (S_T^{\circ})_e]$$
⁽⁹⁾

The enthalpies and entropies of the elements in reference state Mg(ref), Si(ref) and $N_2(ref)$ were taken from NIST-JANAF tables.²⁰ The calculated thermodynamic functions in the temperature range of (298–2500) K are listed in Table 4.

The linear fit of the calculated Gibbs free energy of formation for MgSiN₂ in the temperature range of 1400–1680 K (above the boiling point of magnesium $T_{b,Mg}$ = 1366 K) follows the equation:

$$\Delta_f G_T^{\circ} / (\text{kJ mol}^{-1}) = -676.17 + 0.299T/\text{K}$$
(10)

At temperatures above the melting point of silicon $(T_{m,Si} = 1685 \text{ K})$ the linear fit can be expressed by equation:

$$\Delta_f G_T^{\circ} / (\text{kJ mol}^{-1}) = -698.46 + 0.315T/\text{K}$$
(11)

where T > 1685 K.

A rough estimation of the minimum and maximum values for the $\Delta_f G_T^{\circ}$ of MgSiN₂ was carried out using the following two reactions³¹:

$$2Si_2N_2O + MgSiN_2 = (3/2)Si_3N_4 + (1/2)Mg_2SiO_4$$
(12)

$$(1/2)Si_3N_4 + 2MgO = (1/2)Mg_2SiO_4 + MgSiN_2$$
 (13)

Both reactions proceed to the right at temperatures above 1650 K, 7,32,33 consequently the Gibbs free energy of reactions should be negative, resulting in the following conditions:

$$\Delta_f G^{\circ}(\text{MgSiN}_2) > (3/2)\Delta_f G^{\circ}(\text{Si}_3\text{N}_4) + (1/2)\Delta_f G^{\circ}(\text{Mg}_2\text{SiO}_4) - 2\Delta_f G^{\circ}(\text{Si}_2\text{N}_2\text{O})$$
(14)

$$\Delta_f G^{\circ}(\text{MgSiN}_2) < (1/2)\Delta_f G^{\circ}(\text{Si}_3\text{N}_4) + 2\Delta_f G^{\circ}(\text{MgO}) - (1/2)\Delta_f G^{\circ}(\text{Mg}_2\text{SiO}_4)$$
(15)

From these conditions the minimum and maximum values for $\Delta_f G^{\circ}(MgSiN_2)$ were obtained. The thermodynamic data of $\Delta_f G^{\circ}(Si_2N_2O)$ were taken from Hendry and Fegley,^{34–36} the $\Delta_f G_T^{\circ}$ of other substances from NIST-JANAF tables.²⁰ The results are shown in Fig. 7, together with the calculated $\Delta_f G_T^{\circ}$ of MgSiN₂ from Eqs. (10) and (11). The Gibbs free energy of formation $\Delta_f G^{\circ}(MgSiN_2)$ calculated from C_P° is closer to $\Delta_f G^{\circ}(MgSiN_2)_{min}$.

Finally, it should be pointed out that in the present work the equilibrium conditions have not been attained owing to the flowing nitrogen atmosphere $(1.5 \,\mathrm{L\,min^{-1}})$ and the obtained data are a rough estimation of the real thermodynamic data.

4. Conclusions

MgSiN₂ powder was prepared by direct nitridation of Si/Mg₂Si/Mg/Si₃N₄ powder compact in a temperature range of 1350–1420 °C. The oxygen content of MgSiN₂ was in the range of 0.4–0.6 wt%. The thermal stability examination showed that MgSiN₂ is stable up to 1400 °C at 0.1 MPa N₂ pressure. The activation energy of decomposition calculated from the temperature dependence of weight loss is $\Delta H = 501$ kJ mol⁻¹. The time dependence and nitrogen pressure dependence of MgSiN₂ decomposition was also investigated at constant temperature. MgSiN₂ is stable at 1560 °C in 0.6 MPa nitrogen atmosphere. Using the experimental data together with the heat capacity published in a literature the Gibbs free energy of formation of MgSiN₂ was calculated in a temperature range of (25–2200) °C.

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